Questionnaire of ADTC and edaWorkshop17

May 8 - 10, 2017, Dresden, Germany



1. Keynotes							
Design & Verification of Technology Dependent Electronic Innovations (A. Aal) May 9	excellent	0	0	0	0	0	unsufficient
"Embedded France" and CPS Activities (C. Demeure) May 9	excellent	0	0	0	0	0	unsufficient
Semiconductor Technology Accelerating Innovation and Industrial Productivity (G. Teepe) May 10	excellent	0	0	0	0	0	unsufficient
2. Sessions							
Technical Session M1 (May 8): Ultra-fast Simulation of HW/SW Systems for Timing and Robustness Verification of Embedded Software	excellent	0	0	0	0	0	unsufficient
Technical Session M2 (May 8): Ancona Offers Analog and Mixed-Signal (AMS) Coverage for Nanoelectronics	excellent	0	0	0	0	0	unsufficient
Technical Session M3 (May 8): Sensor-based Electronic Systems for Industry 4.0 Applications	excellent	0	0	0	0	0	unsufficient
Technical Session T1 (May 9): Mobility of Tomorrow	excellent	0	0	0	0	0	unsufficient
Technical Session T4 (May 9): Security for Industrial IoT	excellent	0	0	0	0	0	unsufficient
Technical Session W1 (May 10): Connected Medical Devices	excellent	0	0	0	0	0	unsufficient
Technical Session W2 (May 10): Emerging CMOS Technologies	excellent	0	0	0	0	0	unsufficient
Technical Session W3 (May 10): 5G & ULP Radio	excellent	0	0	0	0	0	unsufficient
Technical Session W4 (May 10): 3D Packaging	excellent	0	0	0	0	0	unsufficient
3. Panel Discussions							
Panel Session T2 (May 9): Long Term Scientific Research Roadmap NEREID	excellent	0	0	0	0	0	unsufficient
4. Poster Exhibition (May 9 - 10)							
The poster exhibition was	excellent	0	0	0	0	0	unsufficient

5. About the event in	n general								
The professional aspect of the event was			excellent	Ο	Ο	0	0	0	unsufficient
The event supported my	personal net	working	excellent	0	0	0	Ο	0	unsufficient
				< 20%	until 40% u	ntil 60	% until 80	% until 10	00%
I knew x percent of the p	participants pe	ersonally		Ο	0	0	Ο	0	
The conference location	Dresden was		excellent	0	0	Ο	Ο	0	unsufficient
My expectations were more than fulfilled			completely agree	0	0	Ο	Ο	0	completely disagree
The overall impression was good			completely agree	Ο	0	0	0	Ο	completely disagree
6. About the joint ev	ent "ADTC	and edaWo	orkshop17″						
I have been participant a	t an edaWork	shop before			yes	0	Ο	no	
I have been participant a (formerly CATRENE DTC		ore			yes	0	0	no	
The co-location of both e	events is a goo	od idea	completely agree	0	0	Ο	Ο	0	completely disagree
I will participate next yea	ar's edaWorks	hop	in any case	0	0	0	0	0	not at all
I will participate next yea	ar's ADTC		in any case	0	0	0	Ο	0	not at all
7. Main reasons for a	ettendance (multinle c	hoices nossible)						
O Refresh existing conta		O Speaker/e	-	0 00	daWorks	non1	17		
O Make new contacts O Technical in				O ADTC					
O Other:									
8. How did you get to	o know abo	ut the ADT	⁻ C and edaWorksho	p17?	,				
O E-Mail	0 www		O Facebook/Twitter/LinkedIn						
O Press	O Colleagues	/Friends	O Known from last year's event						
O Other:									
9. More comments									

Many thanks for completion the questionnaire!

Please return this form to the registration desk before leaving or fax it to **+49 511 762-19695**.